

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	21433	("438"/\$.ccls.) and (ion adj (implant\$3 or inject\$3))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/04 11:29
S2	143	S1 and software and apparatus	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/04 11:31
S3	53	S2 and (phosphorus or boron)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/04 11:30
S4	45	S3 and (substrate near5 (silicon or Si))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/04 11:31
S5	2	S4 and (software same implant\$3 same apparatus)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/02/04 11:31